## NT-P023

## Growth of High Purity Single Walled Carbon Nanotubes Using Alcohol Plasma

## <u>배기열<sup>1</sup>, 정승근<sup>2</sup>, 박완준<sup>1,2</sup></u>

<sup>1</sup>한양대학교 전자통신컴퓨터공학부, <sup>2</sup>한양대학교 나노반도체공학과

In this report, we demonstrated a new growing method of single walled carbon nanotubes (SWNTs) using alcohol plasma. The standard chemical vapor deposition(CVD) was employed with a remote plasma source. It revealed that this growing method is fitted for nanotube growth on substrate with both of catalytic films and nano particles. Raman spectroscopy and scanning electron microscopy (SEM) were resulted that grown nanotubes by the alcohol plasma were easier for growing method and higher in purity than the general CVD.